



Image

2829

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Docket No.: AMD-G0439

I hereby certify that this transmittal of the below described document is being deposited with the United States Postal Service in an envelope bearing First Class Postage and addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on the below date of deposit.

Date of Deposit:	12/15/03	Name of Person Making the Deposit:	Judy Davenport	Signature of the Person Making the Deposit:	
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Serial No.: 10/017,832

Group Art Unit: 2829

Filed: 12/12/2001

Examiner: Robert, Russell Marc

Confirmation No: 5028

Title: METHOD OF DETERMINING GATE OXIDE THICKNESS OF AN OPERATIONAL MOSFET

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

TRANSMITTAL OF FORMAL DRAWINGS

In response to Drawing Informalities

attached please find:

☒ (a) the formal drawings for this application  
Number of Sheets 5

Each sheet of drawing indicates the identifying indicia suggested in § 1.84(c) on the reverse side of the drawing

☐ (b) a copy of the NOTICE OF INFORMAL DRAWINGS

Please direct all correspondence concerning the above-identified application to the following address:

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Respectfully submitted,

Date: 12/15/03

By:   
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